

ABSTRACT OF THE DISCLOSURE

A resin layer including a benzophenone compound is formed on a surface of a glass substrate, and a
5 photoresist layer is formed on a surface of the resin layer. The photoresist layer is irradiated with a laser beam with a wavelength of 100nm to 300nm to form a latent image, and a resist pattern with recessed and protruding parts are formed in the photoresist layer by
10 developing the photoresist layer in which the latent image has been formed.